PATENT APPLICATION Sheet 1 of 1 ATTY, DOCKET NO. SERIAL NO. FORM PTO-1449 10030753-1 LIST OF PATENTS AND PUBLICATIONS FOR **APPLICANT APPLICANT'S INFORMATION DISCLOSURE** Laura Wills Mirkarimi **STATEMENT** FILING DATE (Use several sheets if necessary) Herewith REFERENCE DESIGNATION **U.S. PATENT DOCUMENTS EXAMINER** DOCUMENT NUMBER DATE NAME INITIAL IO. 5,624,529 04/29/97 Randy J. Shul et al. 08/16/94 5,338,394 Mohammed A. Fathimulla et al. **FOREIGN PATENT DOCUMENTS TRANSLATION DOCUMENT** DATE NAME NUMBER YES NO OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, etc.) Chen, Hsin-Yi et al., "Inductively Coupled Plasma Etching of InP using Ch4/H2 and CH4/H2/N2", Journal of Vacuum Science Technology, B 20(1), Jan/Feb 2002, pp. 47-52. 20 Hur, Katerina Y., et al., "Reactive Ion Etching of InP Via Holes", Journal of Vacuum Science Technology, B 12(3), May/Jun 1994, pp. 1410-1412. Feupier, Y. et al., "Influence of the Gas Mixture on the Reactive Ion Etching of InP in Ch4-H2 Plasmas, Journal of Vacuum Science Technology, B 15(5), Sep/Oct 1997, pp. 1733-1740.

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<i>8</i> 0		Grover, Rohit, "Process Development of Methane-Hydrogen-Argon-Based Deep Dry Etching of InP High Aspect-Ratio Structures with Vertical Facet-Quality Sidewalls", Journal of Vacuum Science Technology, B 19(5), Sept/Oct 2001, pp. 1694-1698.						
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